

Design Specifics and Estimated Material Cost

Dean Walters

Engineering Operations

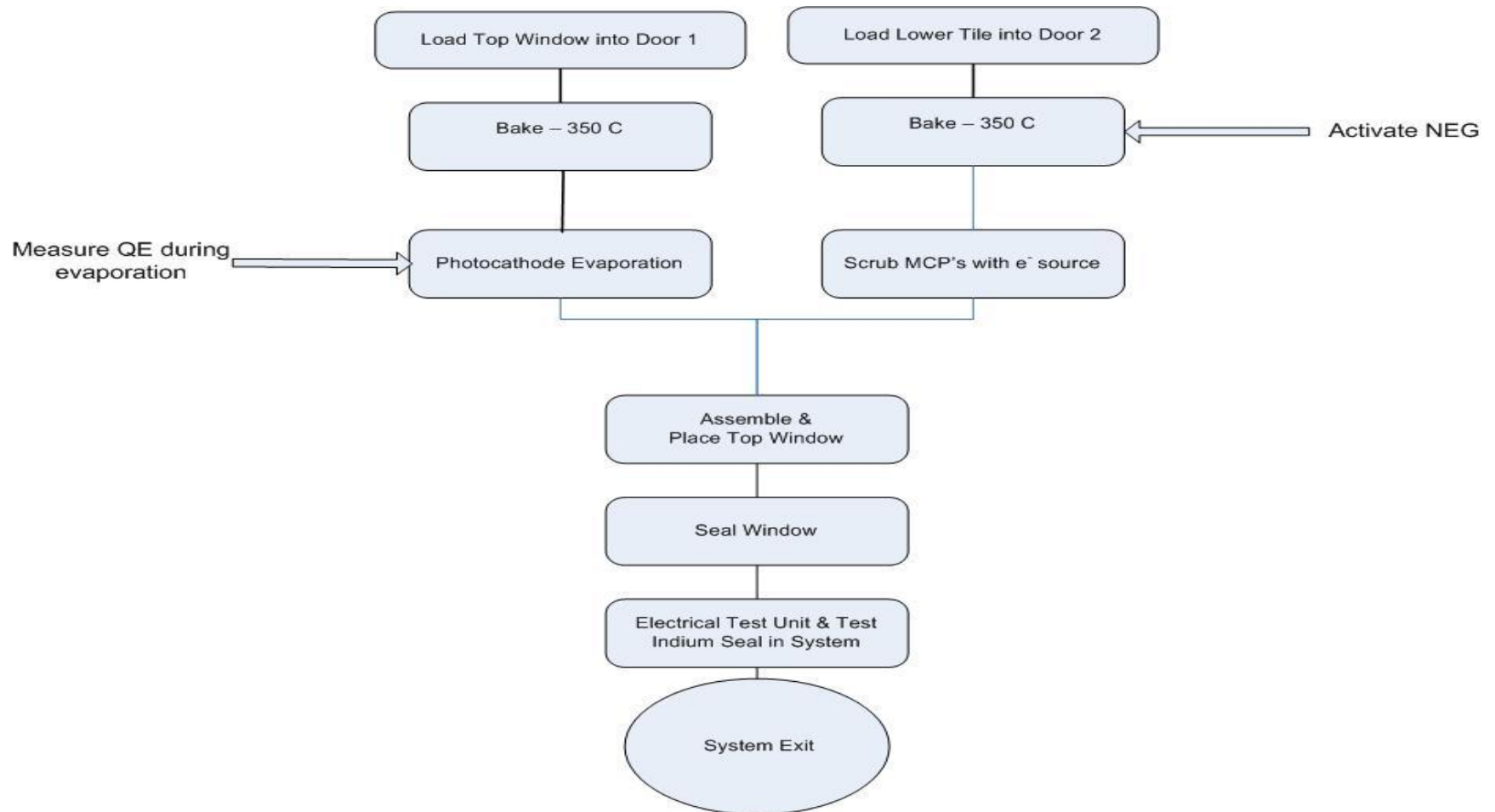
Nuclear Engineering Division

Argonne National Laboratory

Table of Contents

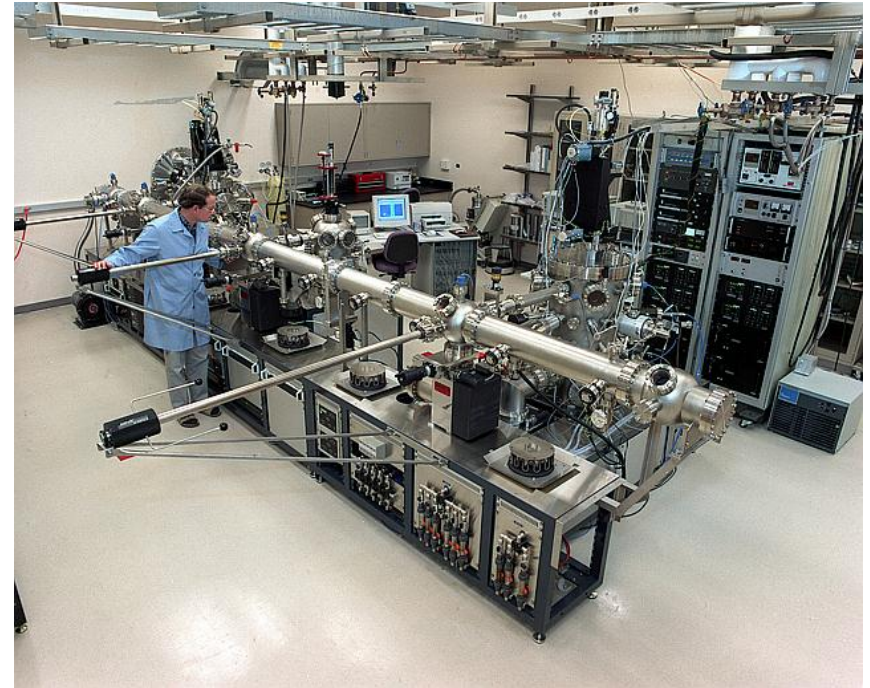
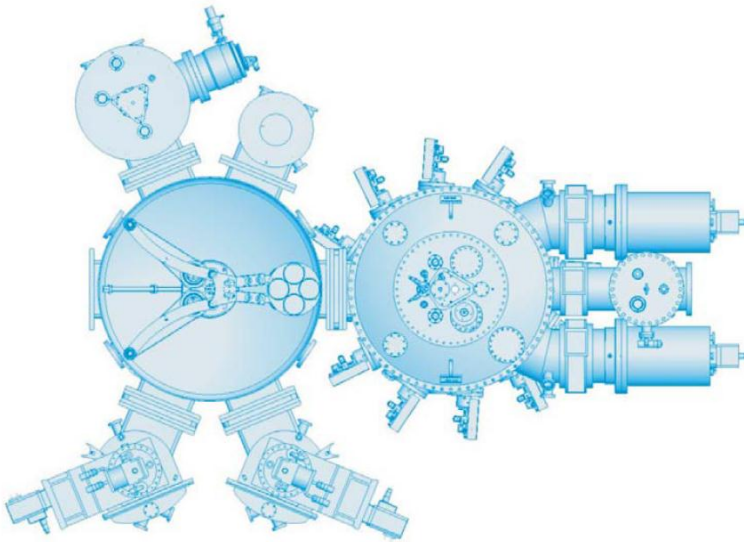
- Design Concept
- Models
- Status of Design
- Component selection
 - Pumps
 - Valves
 - Load lock doors
 - Gauges
- Estimated cost
- Schedule

Material Processing Flow Chart



Design Concept

- Here are two ways to make a multi-process/multi-chamber system
- Cluster tool where each of the process chambers around the parameter is feed by a central manipulator.
- Linear tool where the samples are moved down a central tube.



Design Concepts

Examples of multi-chamber systems made by industry.



- From VG/Oxford



Oxide MBE System with Load Locked Effusion Cell

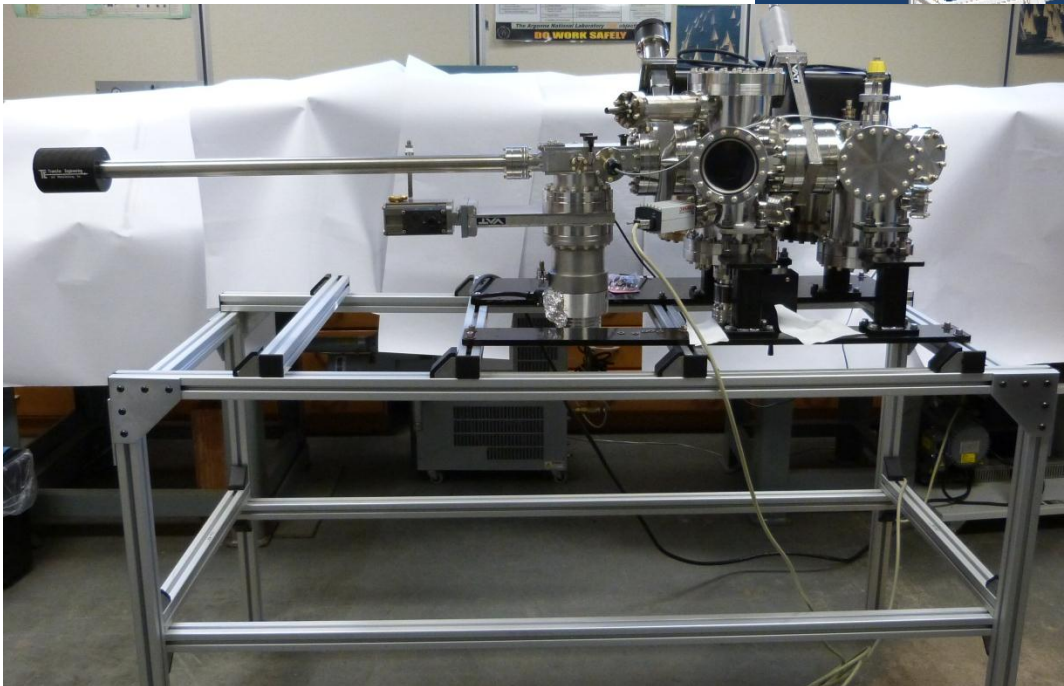
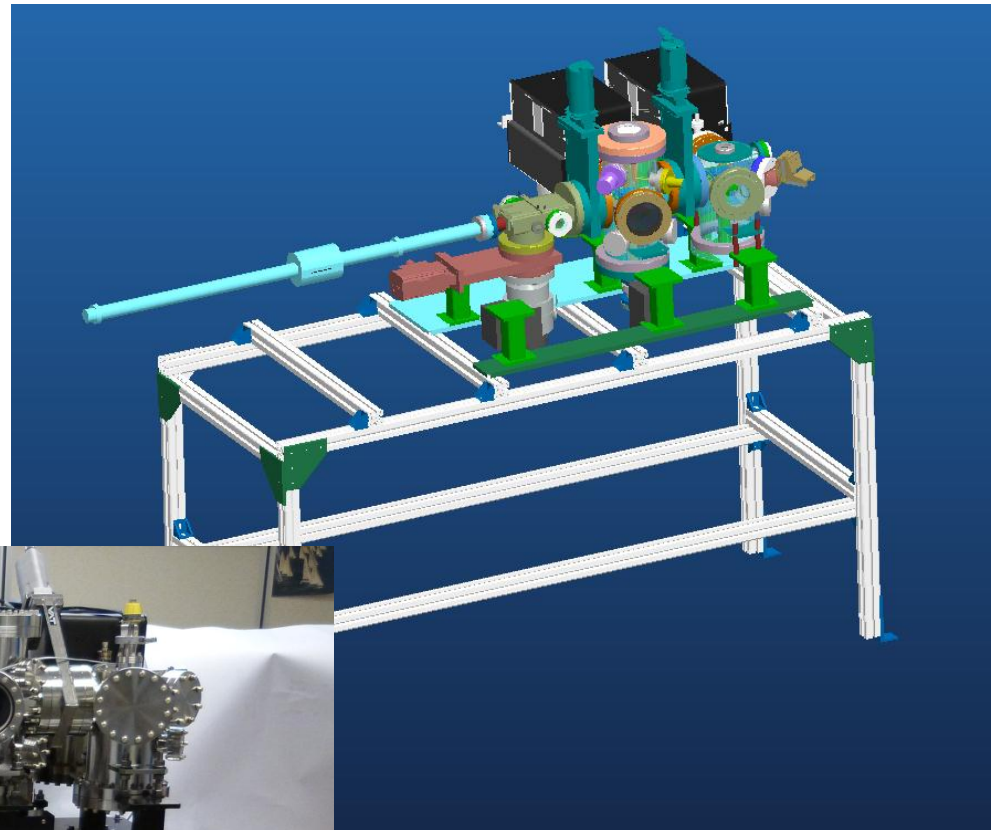


MBE System with STM Module

From SVT Associates

Design Concepts

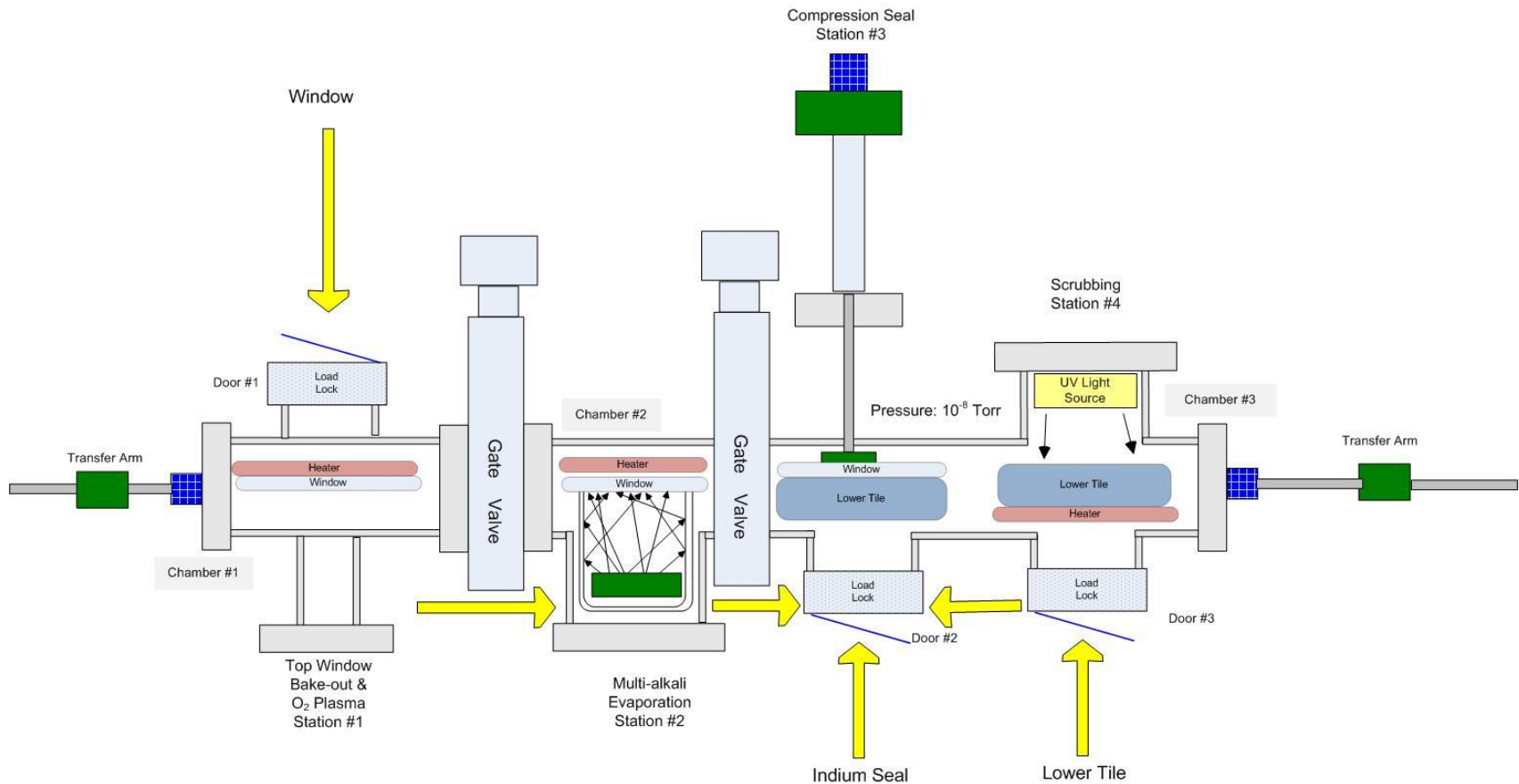
- Example of a linear UHV system using a transfer arm for sample transport.



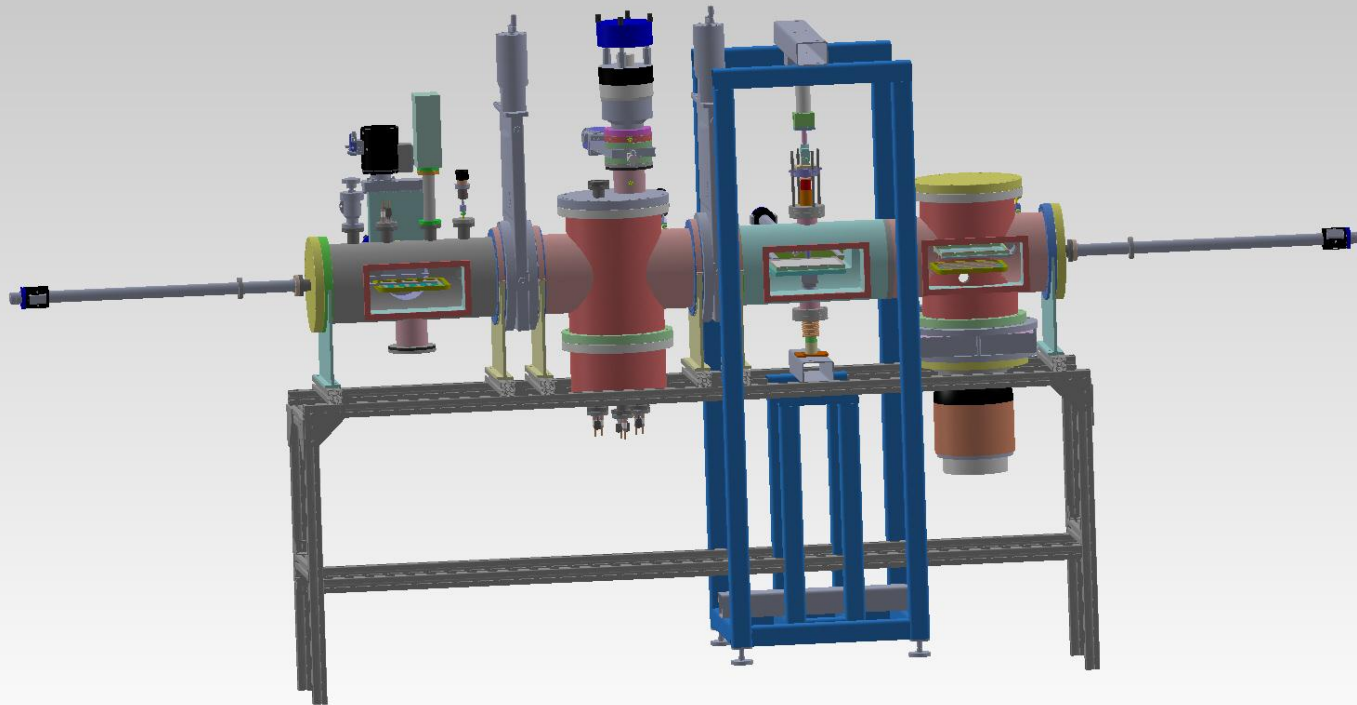
Courtesy of M. Virgo

Schematic of the Single Tile Process System

Single Tile Production Machine

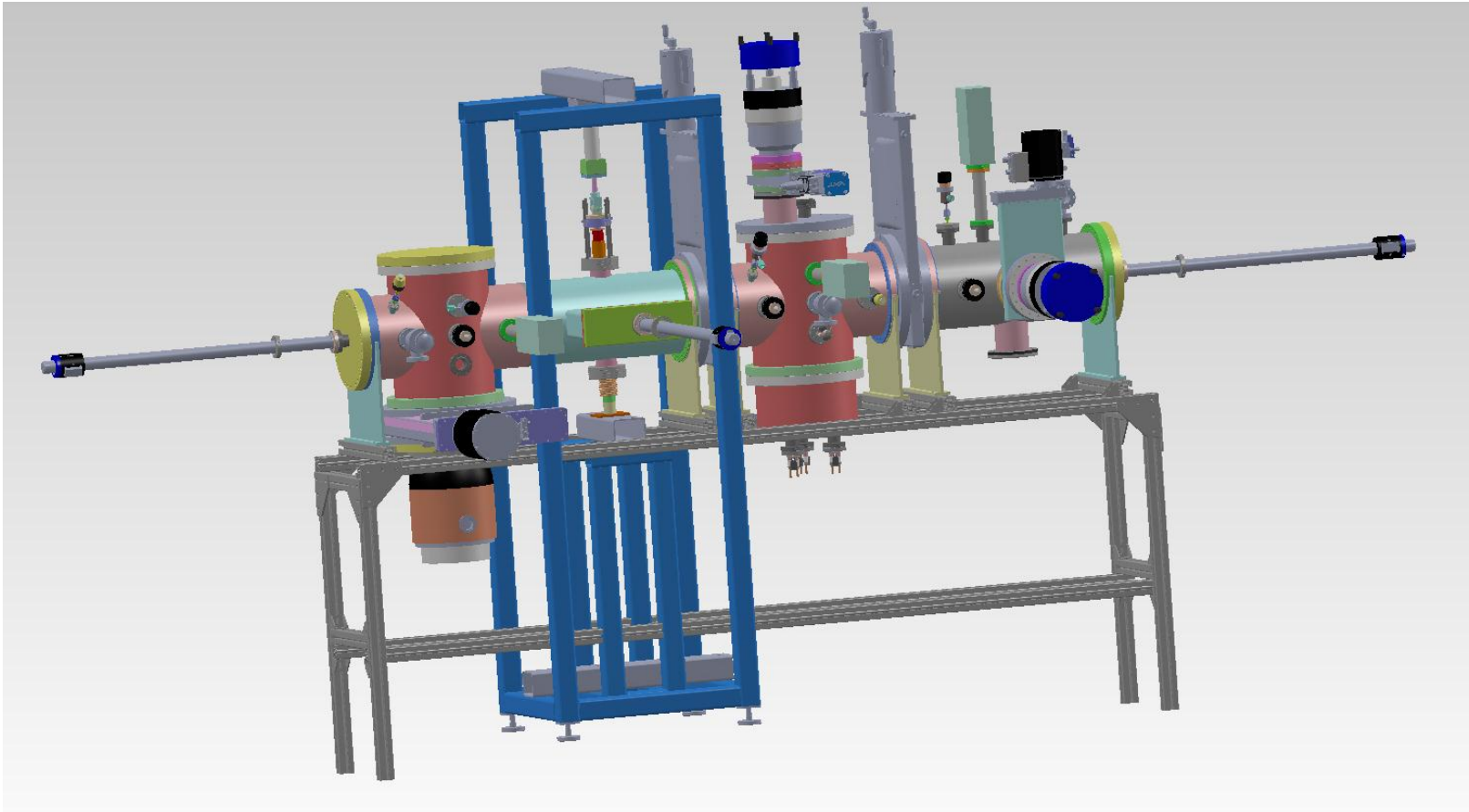


Single Tile System



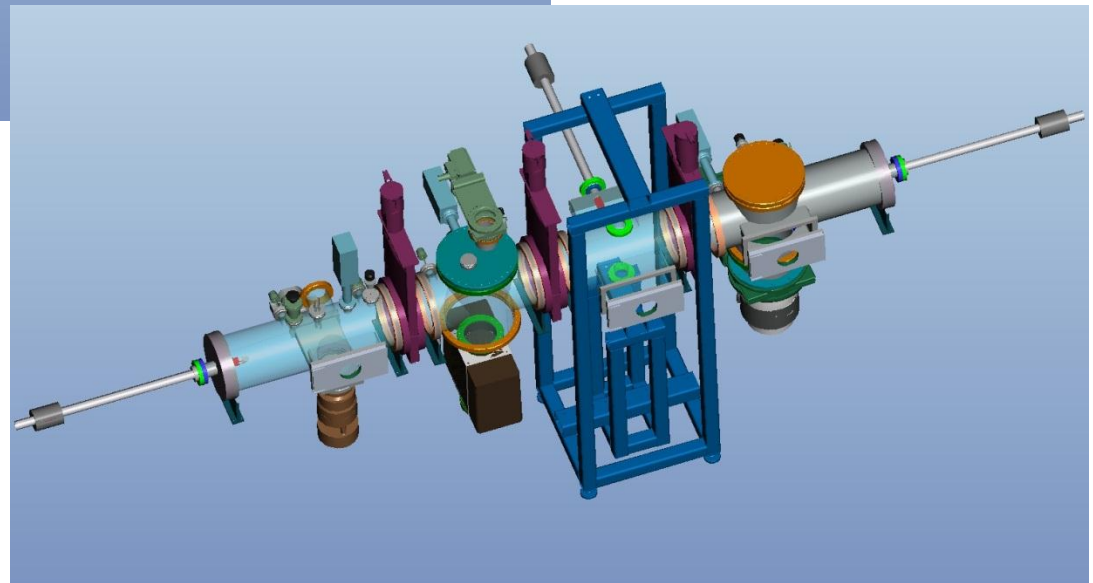
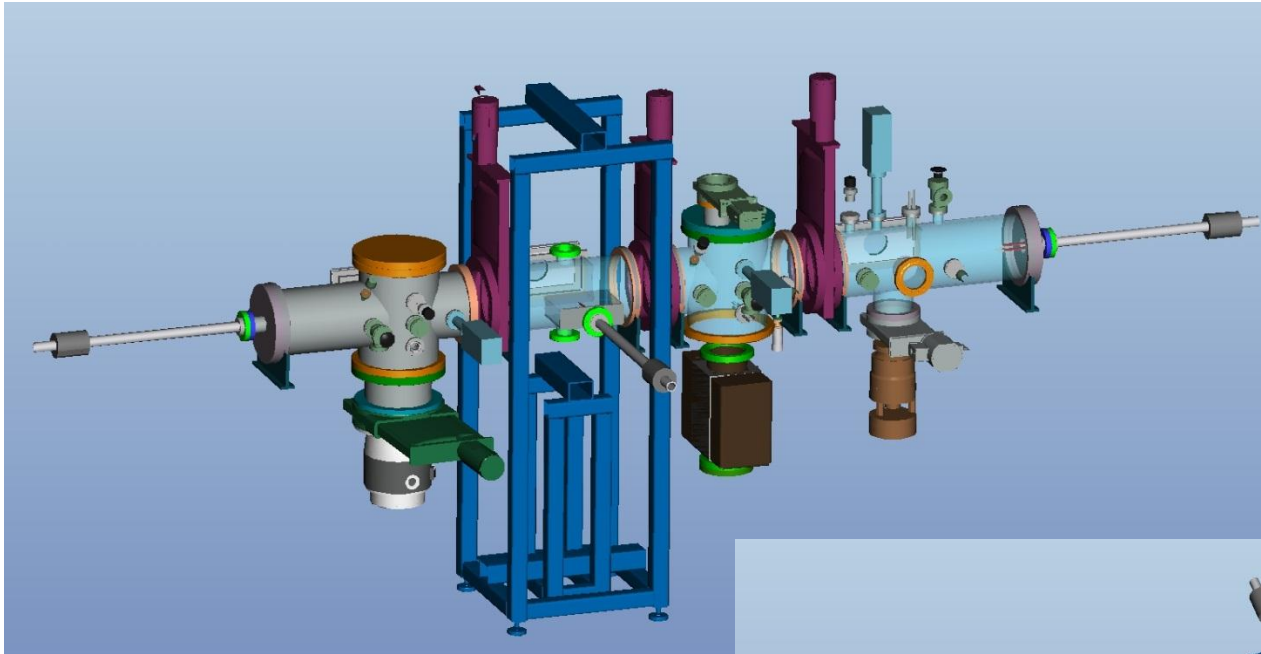
Progress of Design

- What has been started
 - SolidWorks



Models

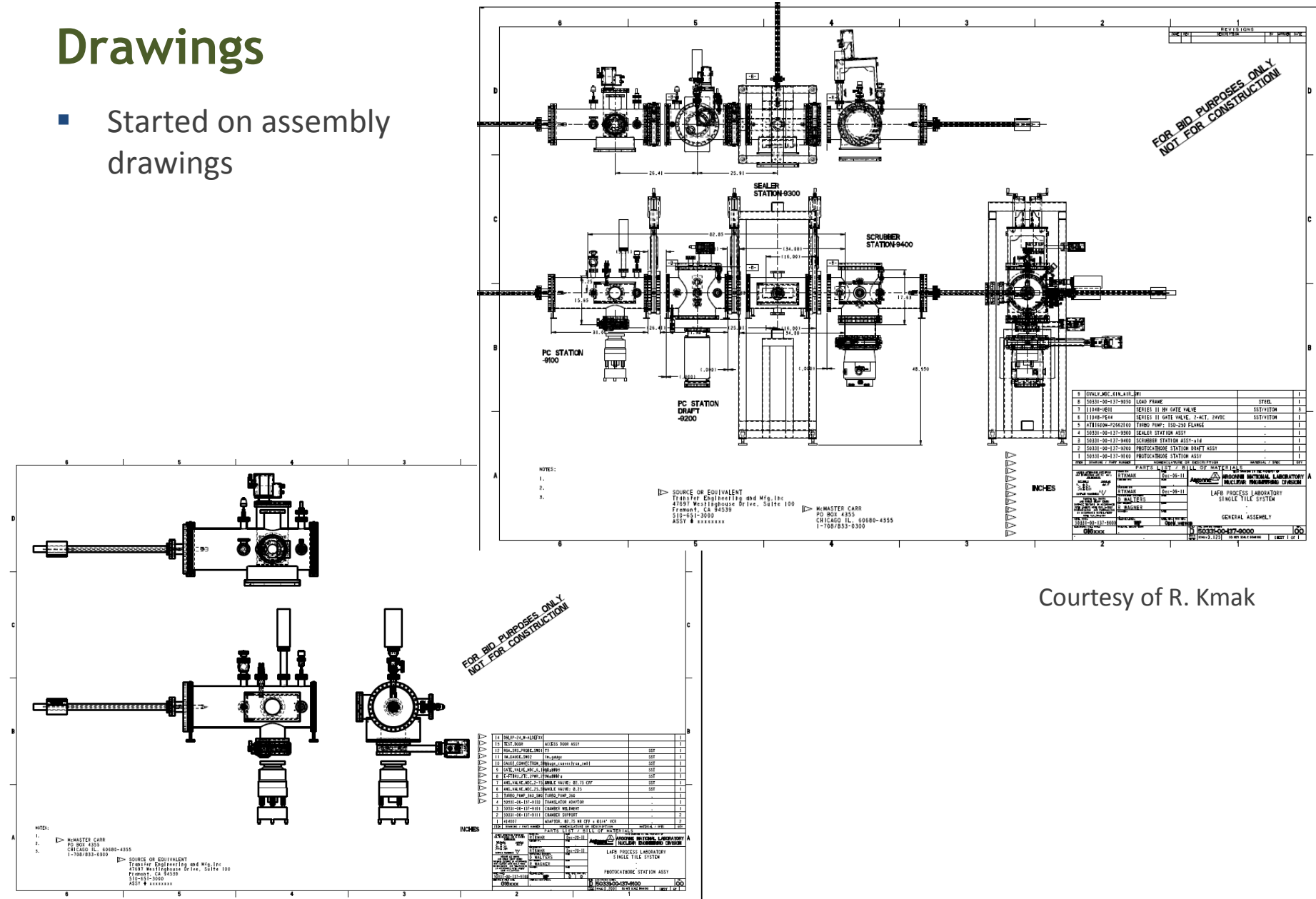
- Pro/Engineer



Courtesy of R. Kmak

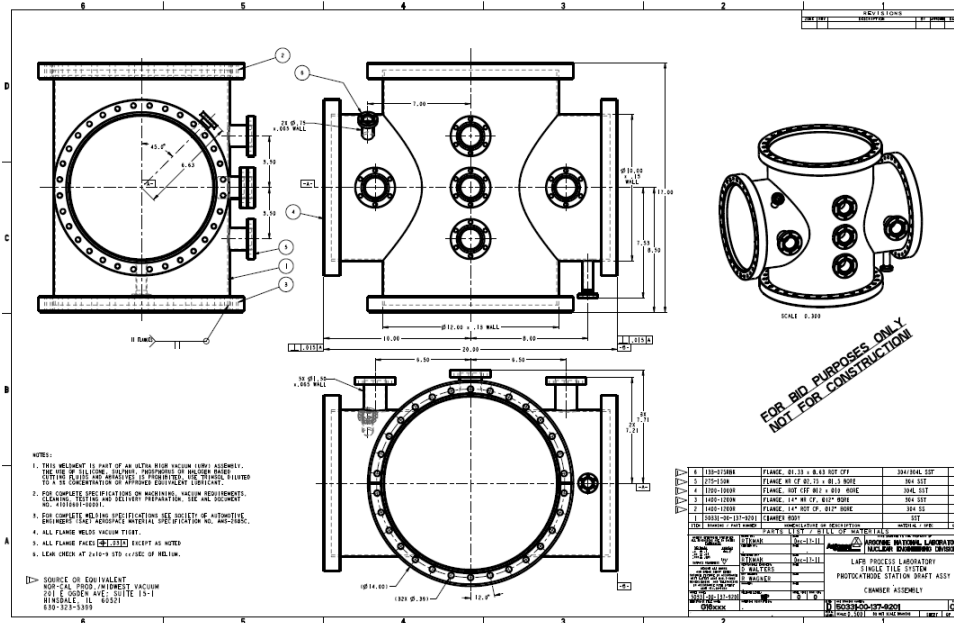
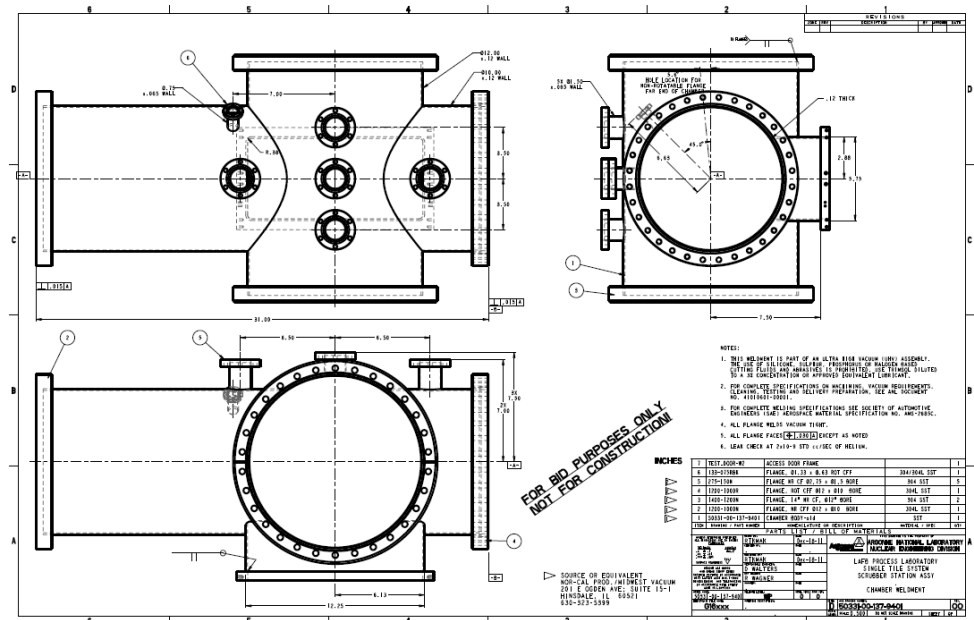
Drawings

- Started on assembly drawings



Courtesy of R. Kmak

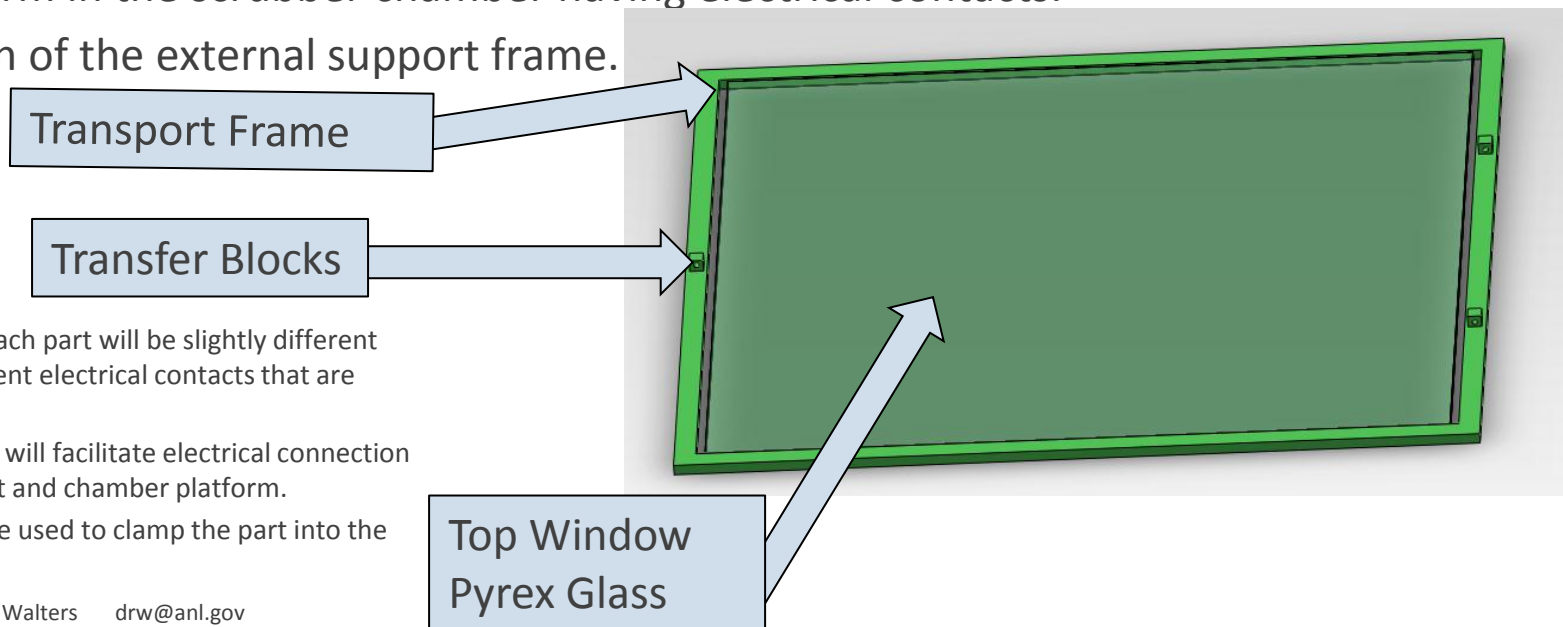
- Started on parts drawings



Courtesy of R. Kmak

What needs to be done

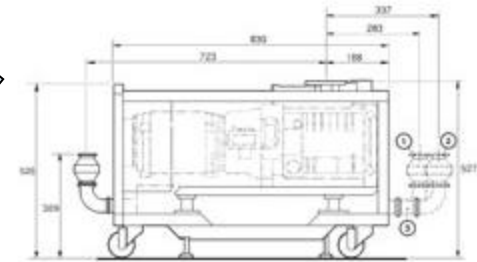
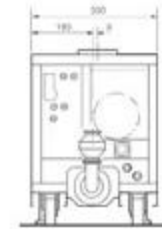
- End effector for transferring the top window.
- End effector for transferring the lower tile.
- Frame for the top window.
- Frame for the lower tile.
- End effector for holding and placing the indium seal.
- Platform in the photocathode chamber which will have electrical contacts.
- Platform in the scrubber chamber having electrical contacts.
- Design of the external support frame.



- The frames for each part will be slightly different due to the different electrical contacts that are needed.
- Use of the frame will facilitate electrical connection between the part and chamber platform.
- Metal clips will be used to clamp the part into the frame.

Component Selection

- Pumps
- Roughing pump
 - Varian dry scroll pump
 - Used in the beginning
 - Edwards QDP80 dry pump
 - Facility pump
- High vacuum pumps
 - Ion pumps
 - Varian
 - Gamma Vacuum
 - Duniway
 - Turbo pumps
 - Leybold 360
 - Alcatel 900
 - In the scrubber and the photocathode subsystems the preferred pump is a turbo pump over an ion pump due to its ability to withstand large gas loads.
 - At the most extreme end of vacuum the ion pump has the advantage but for this application a turbo pump is more that sufficient.



1. Alternative outlet position (without adaptor fitted)
2. Alternative outlet position (with adaptor fitted)
3. Adaptor



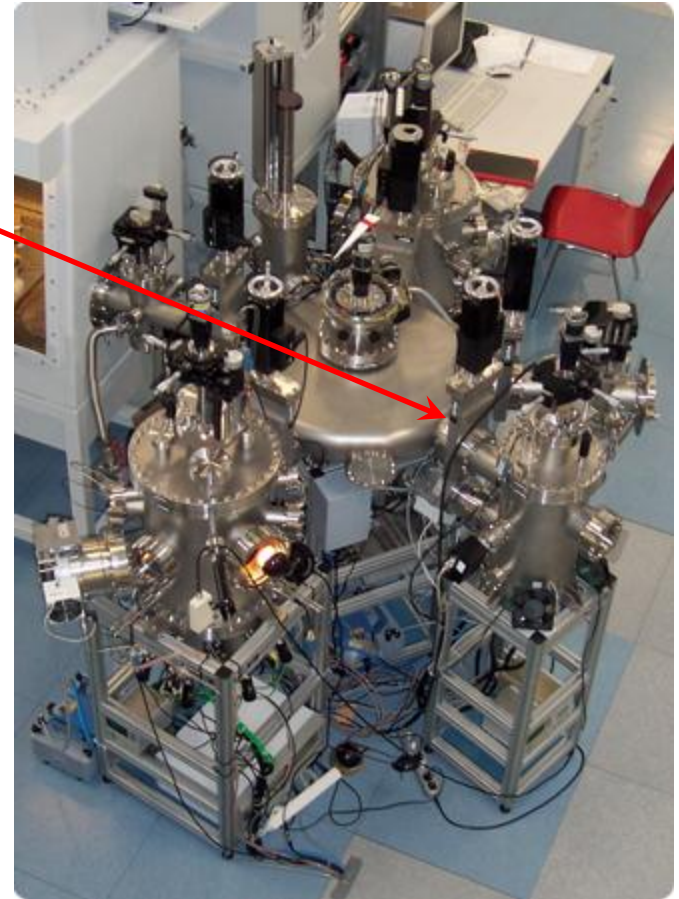
Components

- Valves
 - All metal valves
 - This are by far the most expensive, in this case \$60K each
 - This has the most limited life, 5K cycles for DN250
 - This weighs the most, 344 lbs. for DN250
 - This has the largest insertion length, 5.91 inches
 - This are the best for UHV and XHV applications, $< 1 \times 10^{-10}$ torr
 - Dry lubricant on bearings
 - Metal bonnet with o-ring on seal plate
 - This is the middle price, in this case \$7.3K each
 - This has a life, 50K cycles for DN250
 - This weighs 114 lbs. for DN250
 - This has an insertion length, 3.94 inches
 - This works quite well for UHV applications, 1×10^{-10} torr
 - Dry lubricant on bearings
 - O-ring bonnet with o-ring on seal plate
 - This is the least expensive, in this case \$5.9K each
 - This has the longest life, 200K cycles for DN250
 - This weighs the least, 86 lbs. for DN250
 - This has the shortest insertion length, 3.15 inches
 - These are good for high vacuum (10^{-8} torr) applications
 - Grease on bearings

Components

■ Gate Valves

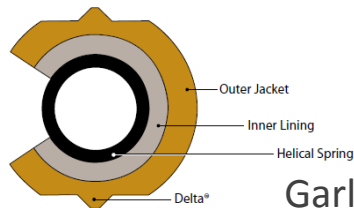
- Current design shows the metal bonnet sealed valve.
 - Good vacuum range
 - Reasonable cost
 - Good bakeout temperature, 250 C.
 - Possible to replace Viton o-ring with Kalrez o-ring.
- All metal valve is a possibility
 - Higher cost
 - Very large weight
 - Will have to design supports for the valve independent of the vacuum chambers.
 - Very good bakeout temperature, 300 C.
- Question comes down to getting to the absolute lowest outgassing rate and the least gaseous contamination.
- This has to be compared to the materials that are being put into the system and whether they pose a bigger problem than what can come from the metal bonnet sealed valve.
- There are many UHV surface science systems that use valves of this type.



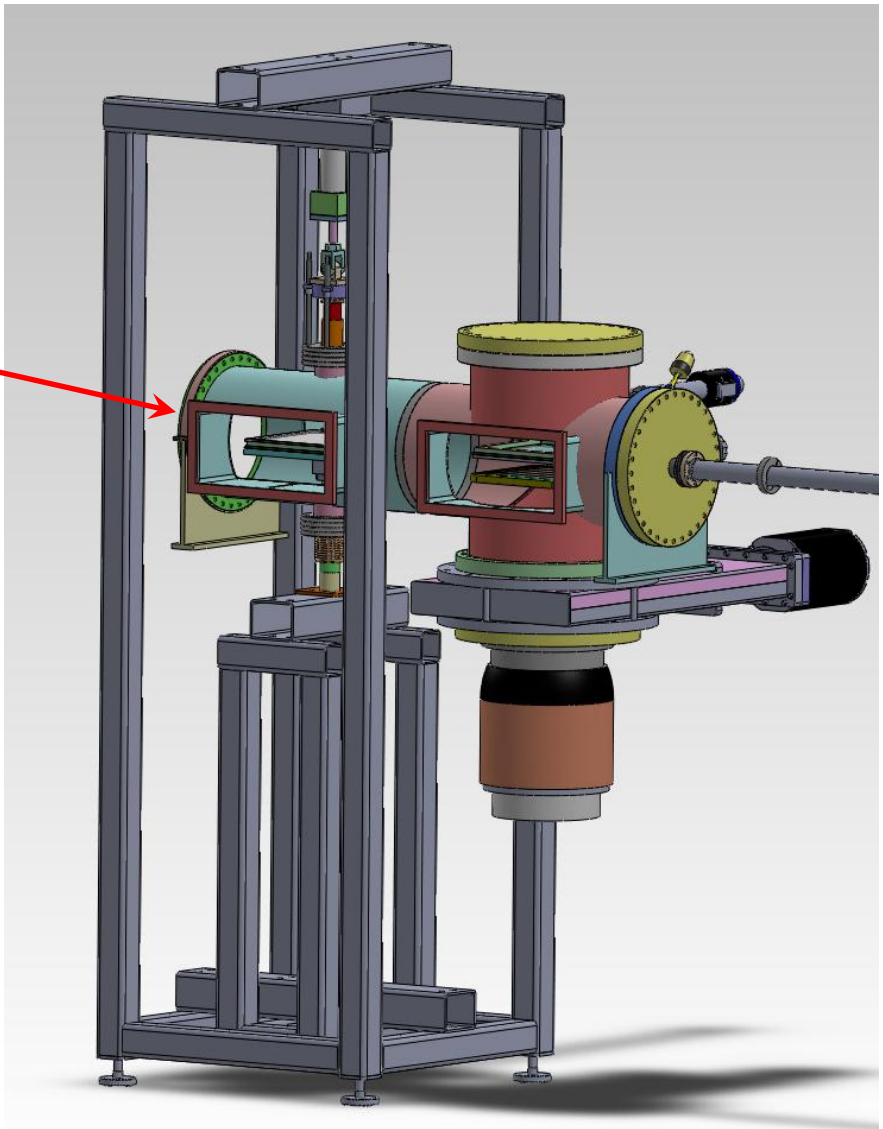
OLED system – VG Scienta

Components

- Load-lock Doors
 - Three ways to go: Viton, Kalrez, & metal
- Viton
 - Bakeable 200 C
- Kalrez
 - Bakeable 250 C
 - Good outgassing
 - More costly
- Metal
 - Helicoflex
 - May require large compression load.
 - Bakeable to 400 C



Garlock Helicoflex Δ Seal



Component selection

■ Gauges

- In this case a hot filament ion gauge was chosen so that it would evaporate off any contaminants that got on it.
- The gas analyzer has an electron multiplier for use at UHV.
- Both units have a computer interface: the ion gauge has RS-485, and the gas analyzer has an Ethernet Port.

Item #	Qty	Part #	Description
1	3	350507-F-T1	350 series UHV ion gauge controller ** 1/2 rack mount ** Reads one series 274 UHV nude Bayard-Alpert gauge ** Reads two Convectron gauges ** 3-line display ** Electron bombardment degas ** Remote input/output interface ** RS-232 or RS-485 switchable ** 4 setpoint relays ** Torr readout ** 115 v.
2	3	274042	UHV Nude Gauges ** Dual thoriated-iridium filaments ** 2.75" CF flange ** Pin guard/locking strain relief
3	3	275238	Convectron gauge ** Gold-plated tungsten filament ** 2.75" CF flange
4	3	275196	Convectron gauge ** Gold-plated tungsten filament ** KF25 flange
5	3	350004-C	UHV nude ion gauge cable (10 ft length) ** Bakeable to 150 c
6	3	303040-10	Dual Convectron gauge cable (10 ft length)

Item	Units	Description
1	1 ea.	Dycor LC-D200M Mass Spectrometer Includes LC-D Series Electronics unit and Analyzer Head, with following features 1 1-200 AMU Range 1 Open Ion Source 1 Faraday Cup Detector 1 Channel Plate Electron Multiplier 1 Ethernet Port 1 24VDC external power supply 1 System 200 software for Windows 98 through Windows 7 The System 200 software includes the same graphical user interface as the System 2000 software, but with a subset of the features of the System 2000 software. PC not included with system. PC supplied by customer must include the following minimum features: IBM compatible Pentium-class processor, with Windows 98 through Windows 7 capabilities

Estimated Material Cost

- Overall

Material Estimate

						Standard		All Metal
Single Tile System						\$191,884		\$297,424
Photocathode Coating Subsystem						\$56,915		\$56,915
Scrubber Station						\$57,148		\$57,148
Indium Sealing Subsystem						\$24,843		\$24,843
Loadlock Subsystem						\$35,678		\$35,678
Gate Valves - Subsystem Isolation (2)						\$16,300		\$119,840
Frame(s)						\$1,000		\$3,000

- Photocathode Subsystem

[illegible]

Estimated Cost

■ Load lock Substation

Load lock Subsystem				\$35,678	
1)	Vacuum Chamber				
a)	Chamber			\$8,415	Quote
2)	Heater and Controls				
a)	Heater Assembly			\$2,550	Quote
b)	Heater Brackets			\$150	Estimate
c)	Heater Controls			\$3,250	Quote
3)	Vacuum Valves				
a)	Gate Valve			\$3,920	Quote
b)	Roughing Valve			\$480	Web
c)	Venting Valve			\$464	Web
d)	Foreline Valve			\$414	Web
4)	Pumping				
a)	Turbo Pump			\$4,600	Web
b)	Controller			\$1,900	Estimate
c)	Cable			\$180	Estimate
5)	Vacuum Instrumentation				
a)	High Vacuum Gauge			\$552	Quote
b)	Low Vacuum Gauge			\$170	Quote
c)	Gauge Controller			\$2,366	Quote
d)	HV Gauge Cable			\$189	Quote
e)	LV Gauge Cable			\$100	Quote
7)	Sample Transfer				
a)	Manipulator			\$4,528	Quote
b)	End Effector			\$1,050	Quote
c)	Spatula			\$400	Estimate

Estimated Cost

■ Indium Sealing Subsystem

Indium Sealing Subsystem						\$24,843		
1)	Vacuum Chamber							
a)	Chamber					\$7,780		Quote
2)	Heater and Controls							
a)	Heater Assembly					\$2,550		Quote
b)	Heater Brackets					\$150		Estimate
c)	Heater Controls					\$3,250		Quote
3)	Pumping							
a)	Ion Pump					\$2,770		Web
b)	Controller					\$2,030		Web
c)	Cable					\$335		Web
4)	Sample Transfer							
a)	Manipulator					\$4,528		Quote
b)	End Effector					\$1,050		Quote
c)	Spatula					\$400		Estimate

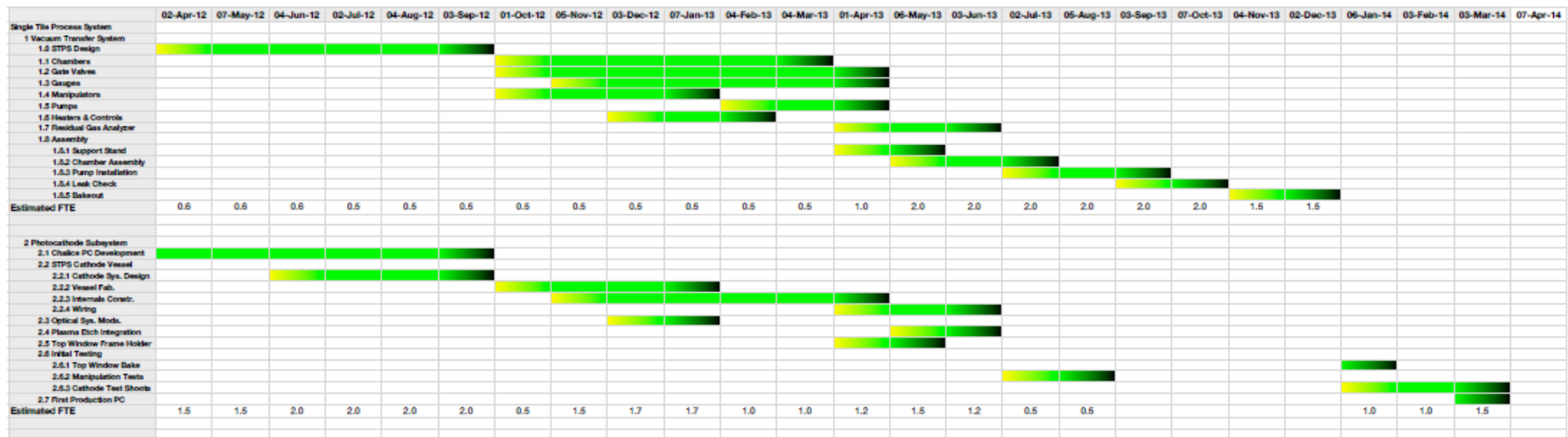
Estimated Cost

■ Scrubber Subsystem

Scrubber Subsystem				\$57,148	
1)	Vacuum Chamber				
a)	Chamber			\$7,780	Quote
b)	Scrubber Element			5,000	WAG
2)	Heater and Controls				
a)	Heater Assembly			\$2,550	Quote
b)	Heater Brackets			\$150	Estimate
c)	Heater Controls			\$3,250	Quote
3)	Vacuum Valves				
a)	Gate Valve			\$8,350	Quote
b)	Roughing Valve			\$480	Web
c)	Venting Valve			\$464	Web
d)	Foreline Valve			\$414	Web
4)	Pumping				
a)	Turbo Pump			\$9,500	Web
b)	Controller			\$1,900	Estimate
c)	Cable			\$180	Estimate
5)	Vacuum Instrumentation				
a)	Residual Gas Analyzer			\$7,775	Quote
b)	High Vacuum Gauge			\$552	Quote
c)	Low Vacuum Gauge			\$170	Quote
d)	Gauge Controller			\$2,366	Quote
e)	HV Gauge Cable			\$189	Quote
f)	LV Gauge Cable			\$100	Quote
7)	Sample Transfer				
a)	Manipulator			\$4,528	Quote
b)	End Effector			\$1,050	Quote
c)	Spatula			\$400	Estimate

Schedule

- Copy of the schedule that Bob Wagner compiled.



Finish

- Any Questions?

- Thanks to
 - Ron Kmak
 - Marc Kupfer
 - Robert Wagner
 - Jeff Williams
 - Michael Ackeret, Transfer Engineering
 - Tom Bogdan, MDC Vacuum
 - Ken Coates, Thermionics Northwest
 - Scott Dix, Vacuum One
 - Hans Luedi, Midwest Vacuum